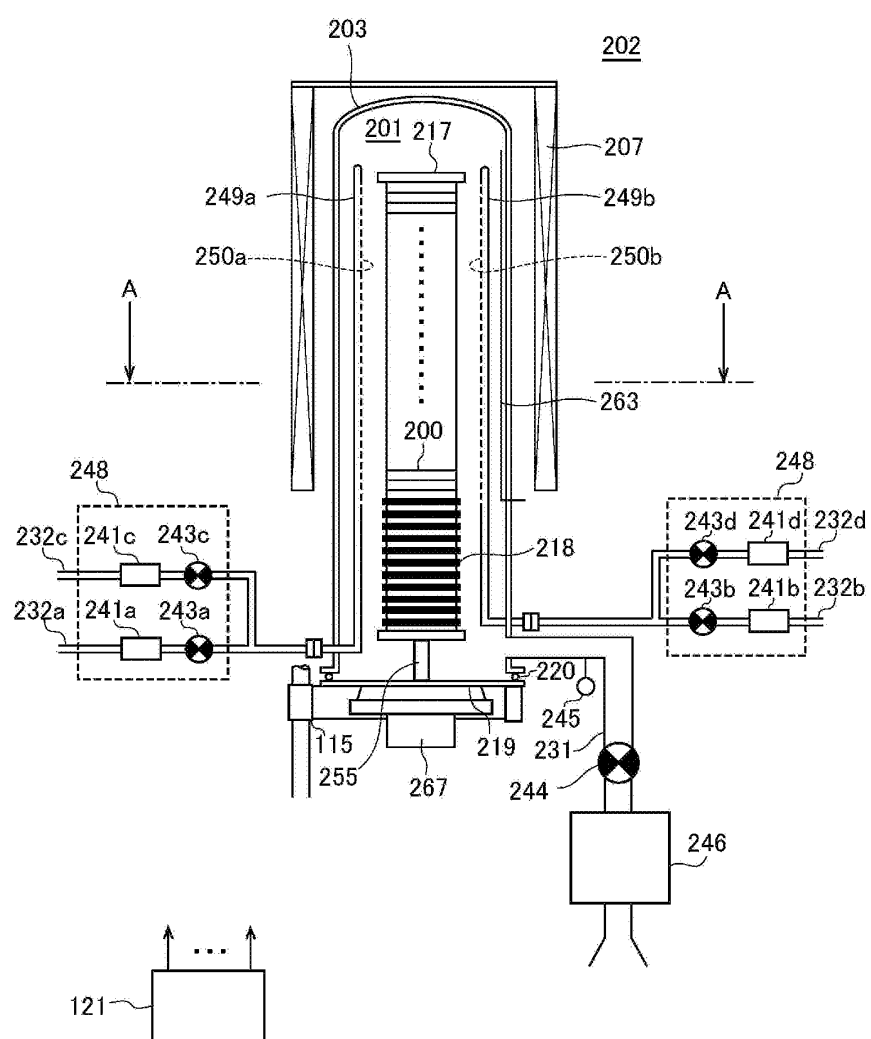
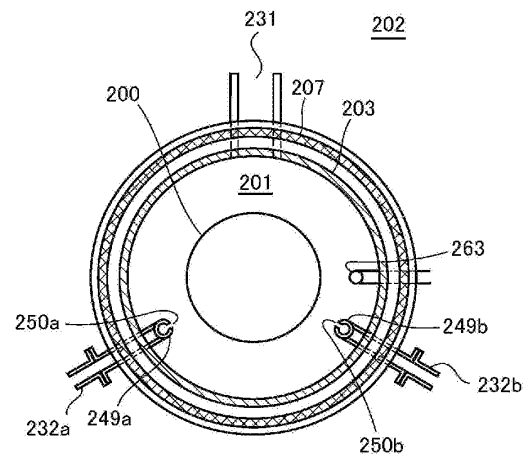


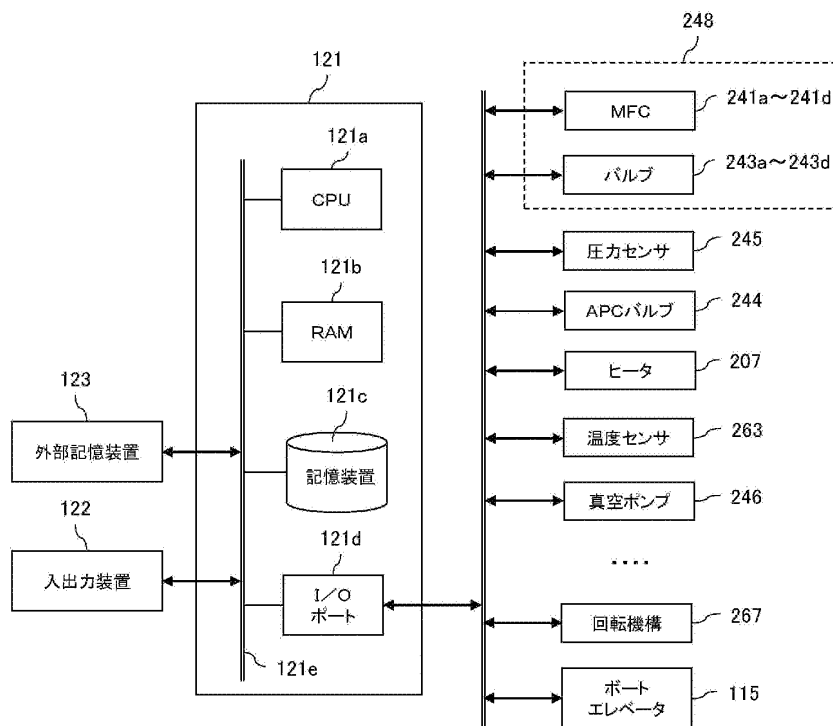
[圖1]



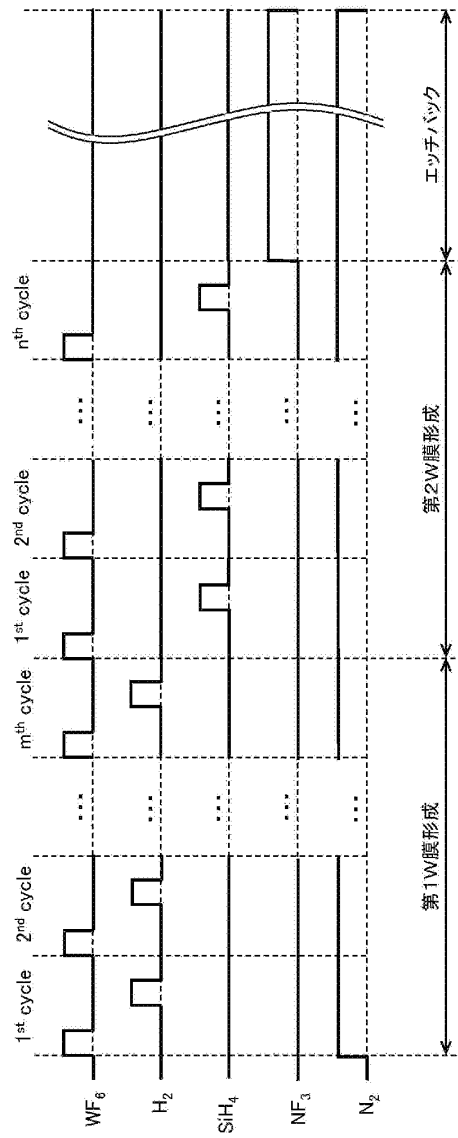
【図2】



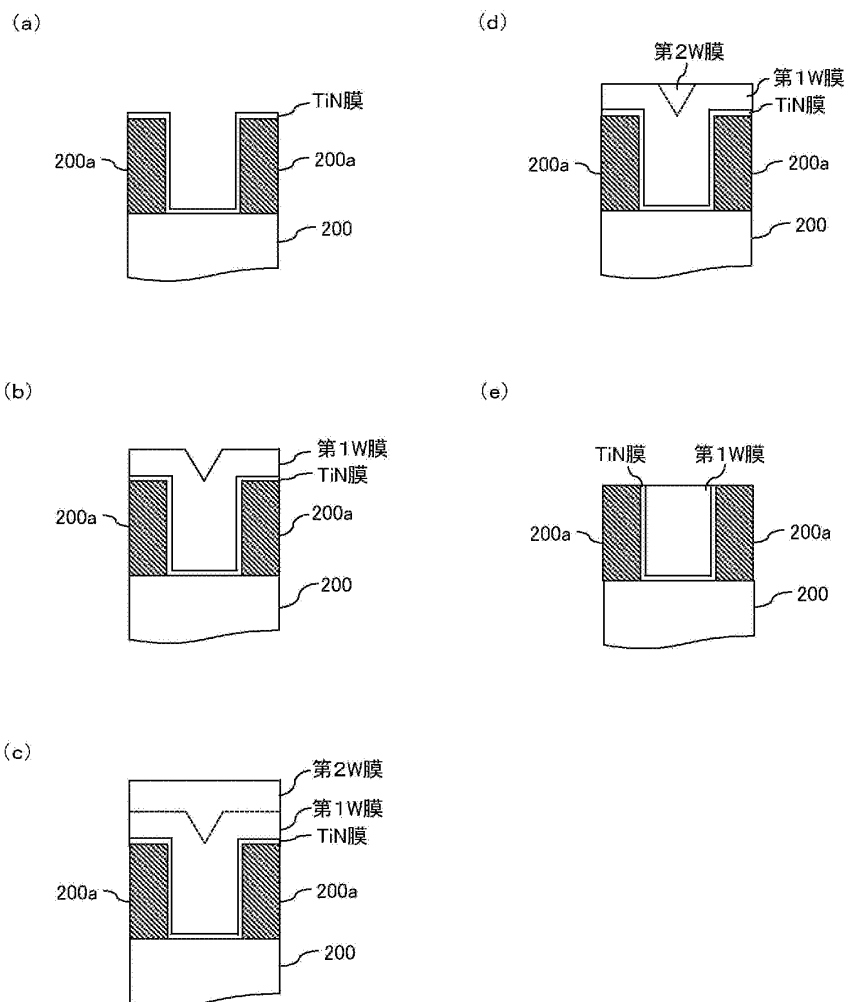
【図3】



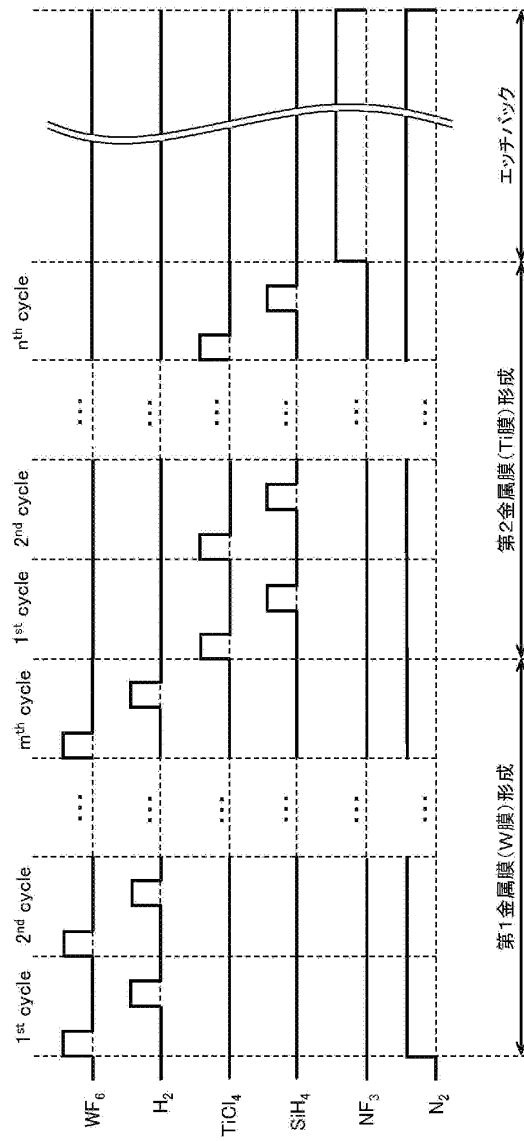
[図4]



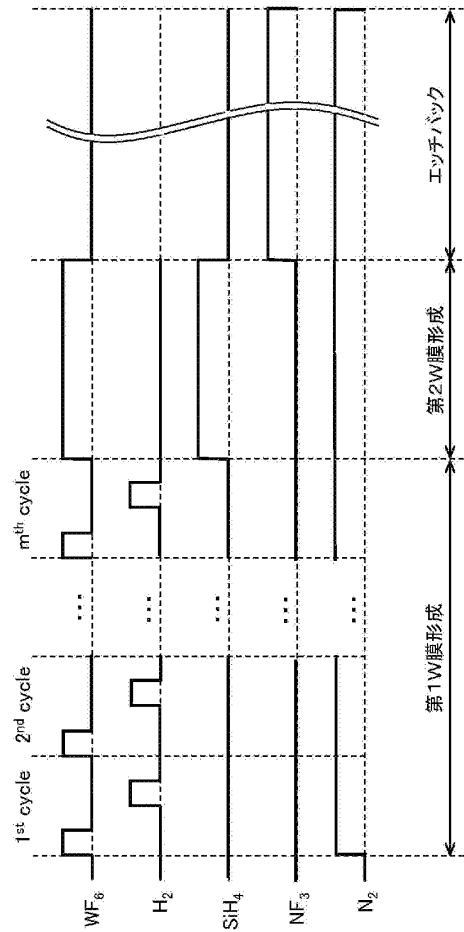
[図5]



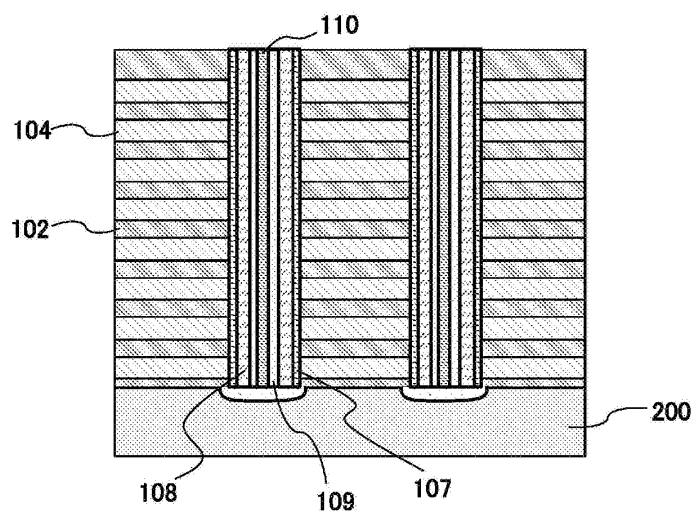
[図6]



[図7]



[図8]



[図9]

(a)

	W膜形成処理の トータル処理時間
実施例	5.98hr
比較例	9.75hr

(b)

第1W膜の成膜レート	0.023nm/cycle
第2W膜の成膜レート	0.83nm/cycle